



UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Chris E. Barns et al.

Serial No.: 10/629,127

Filed: July 29, 2003

For: Preventing Silicide Formation at
the Gate Electrode in a Replacement
Metal Gate Technology

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Art Unit: 2822

Examiner: Khanh B. Duong

Docket: ITL.1016US
P16703

Mail Stop **RCE**
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT ACCOMPANYING RCE

Sir:

This paper is submitted in conjunction with the enclosed Request for Continuing Examination (RCE) in the above-identified Patent Application. Further examination and reconsideration are respectfully requested in view of the Amendments set forth below.

Amendments to the Claims begin on page 2 of this paper.

Date of Deposit: January 11, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.


Ellen Peacock